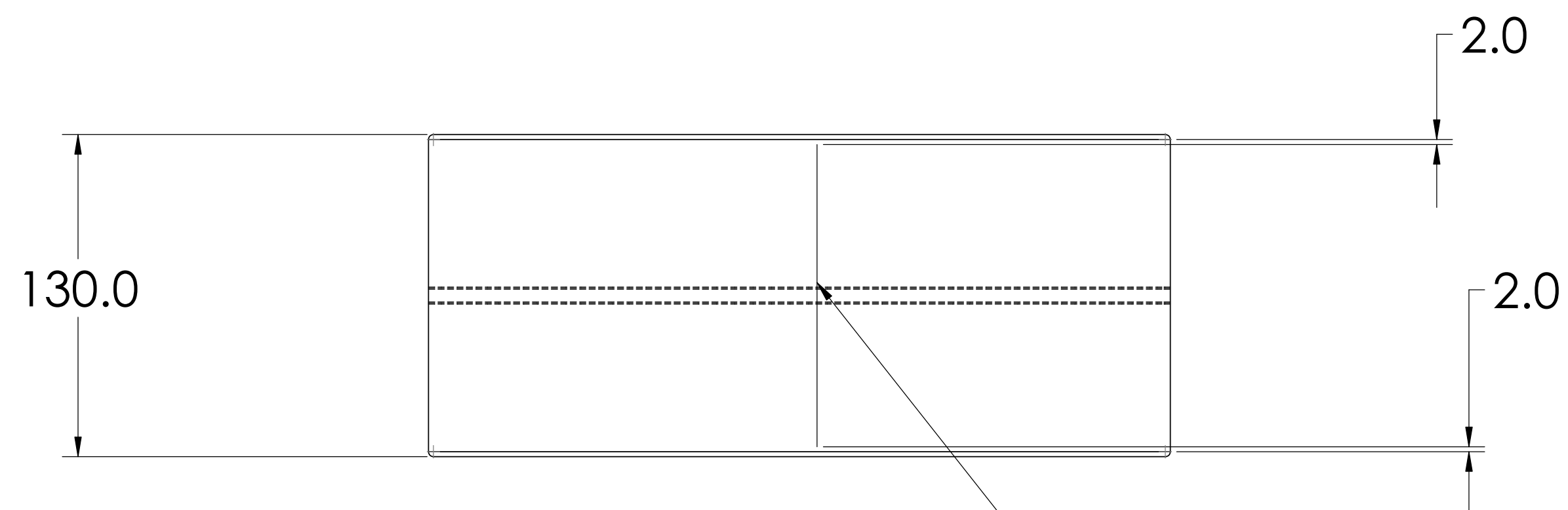
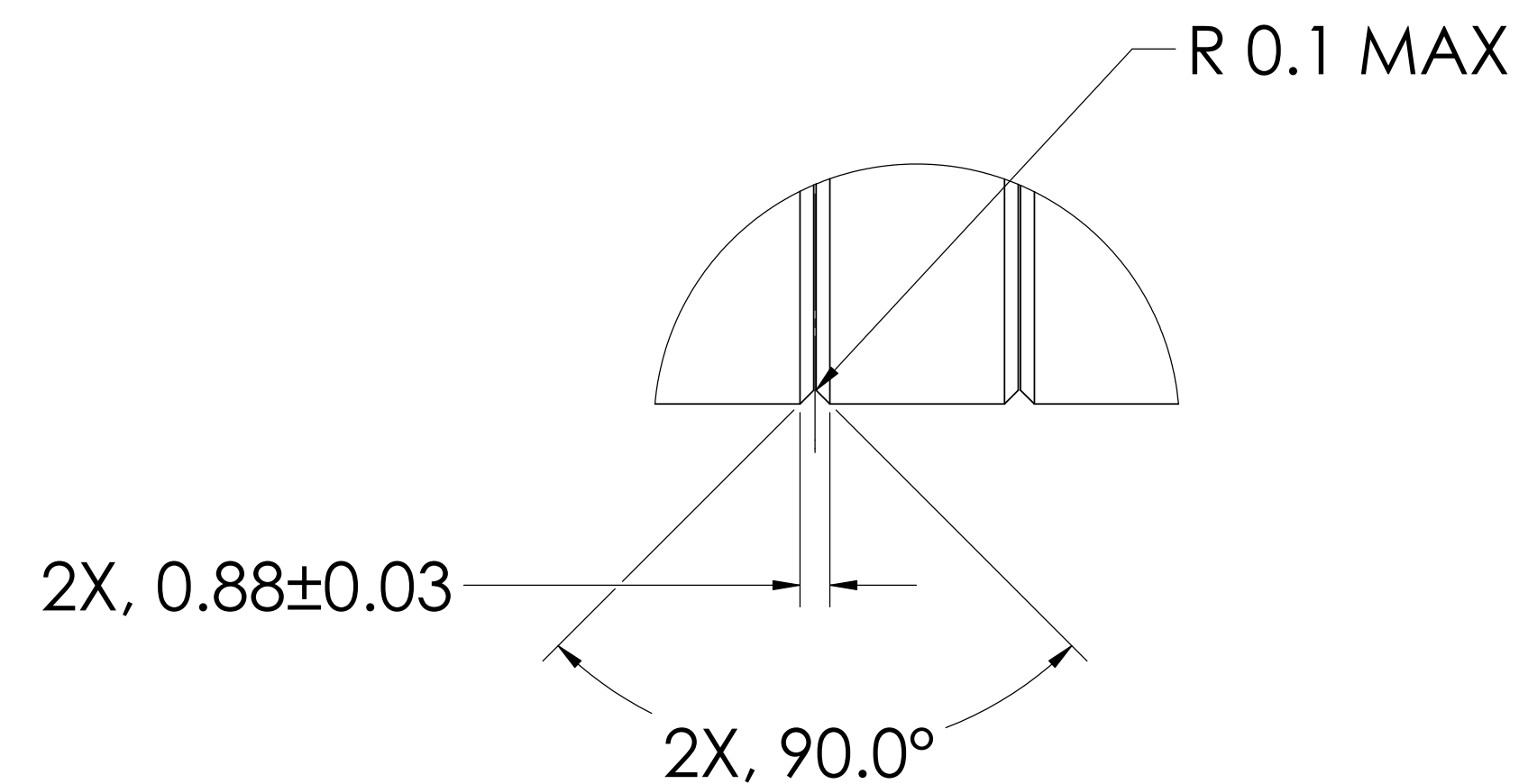


REV.	DATE	DCN #	DRAWING TREE #



2X, ETCH OR GRIND .25mm +/- .05mm WIDE X DIMENSION SHOWN, 180 ° APART, PARALLEL TO A.



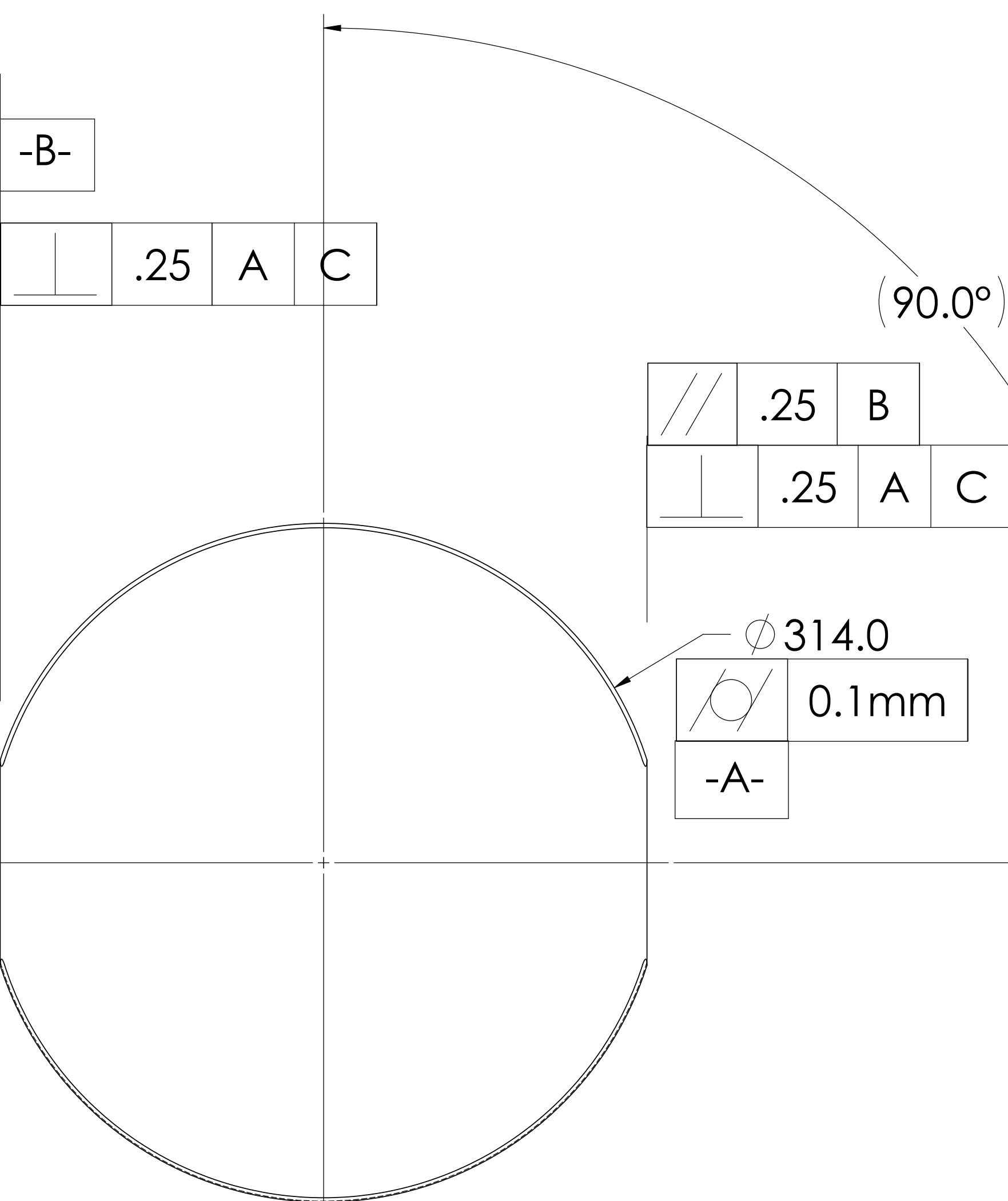
DETAIL B
SCALE 5 : 1

2X, 2.0
CHAMFER, ALL AROUND

-C-

ETCH OR GRIND DRAWING NUMBER AND SERIAL NUMBER, APPROX. WHERE SHOWN, LETTERING APPROX. 4mm HIGH.

2X, 47.5
MEASURED FROM SHARP



2X, 95.0
MEASURED FROM SHARP

SURFACE 2

SURFACE 1

2X,
ETCH OR GRIND
.25mm ± 0.50mm
WIDE X DIMENSIONS SHOWN,
AT 90.0° AND 180.0°
POSITIONS.

2X, 2.0
4X, 25.0

2X, 2.0

3.0
6.0

NOTES (UNLESS OTHERWISE SPECIFIED)		PARTS LIST	
NOTES: 1. POLISH ALL FACES, EDGES AND CHAMFERS. FLATNESS TO BEST SHOP QUALITY. 2. SIDE FLATS TO BE POLISHED TO 1/10 WAVELENGTH FLATNESS AT 633 nm OVER THE CENTRAL 60 mm. SURFACE QUALITY 60/40.		DIMENSIONS ARE IN MILLIMETERS TOLERANCES: X ± 0.1 ANGULAR ± 0.5 °	
MATERIAL: SF2 HEAVY GLASS		FINISH: SEE NOTES	
DRAWN: J. ROMEO DATE: 6/04		PART NAME: PENUL. MASS ETM SUBSTRATE	
CHECKED: APPROVED:		SYSTEM: ADVANCED LIGO SUB-SYSTEM: SUS NEXT ASSY: QUAD ETM	
SCALE: 1:2 PROJECTION:		SITE DWG. NO.: D040278 REV.: 01	
SHEET 1 OF 1		SHEET 1 OF 1	